Analysis of emissions from prebunched electron beams

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The emissions of the prebunched electron beam, including the coherent spontaneous emission and the self-amplified stimulated emission, are analyzed by using one-dimensional FEL theory. Neglecting the interaction of the electrons and the radiation field, the formula of the coherent spontaneous emission is given, the power of which is proportional to the square of the initial bunching factor and of the undulator length. For the general emission case of the prebunched electron beam, the evolution equation of the optical field is deducted. Then the analytical expression of the emission power is obtained for the resonant case; it is applicable to the regions from the low gain to the high gain. It is found that when the undulator length is shorter than four gain lengths, the emission is just the coherent spontaneous emission, and conversely, it is the self-amplified stimulated emission intensity with the detuning parameter for different interaction length are presented. The radiation field characters of the prebunched electron beam are discussed and compared with that of the seeded FEL amplifier.

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I. INTRODUCTION

An important basic concept of the free electron laser (FEL) is the bunching. When the electrons pass through the magnetic field of an undulator, they interact with an optical field whose wavelength resonates with the radiation wavelength. Depending on the phase relative to the optical field the electrons experience either a deceleration or an acceleration, thus it leads to an energy modulation of the electrons. As the energy modulated electrons go on traveling in the undulator, the fast and the slow electrons follow the paths of different lengths in the undulator magnetic field. Hence the energy modulation is transformed into a density modulation, i.e. the microbunching on the scale of the optical wavelength is formed. Consequently, the radiation from the microbunched electrons is coherently enhanced.

If prior to injection into the undulator the electron beam is prebunched on the scale length comparable with (at least) or shorter than the resonant wavelength, then the coherent radiation will be developed quickly. The prebunching mode [1–4] can be used for compact FELs, such as intense narrow-band THz superradiance sources [5–7], as well as high gain x-ray FELs [8–9], to not only shorten the saturation length but also improve the longitudinal coherence. In this paper, the emissions of the prebunched electron beam are analyzed by using the one-dimensional FEL theory. We analyze the coherent spontaneous emission and the self-amplified stimulated emission of the prebunched electron beam. We consider the case of a FEL operating with the sustained electron pulse train. The paper is organized as follows: First, the basic equations of the radiation optical field with the prebunched electron beams are presented (Sec. II), and then we deduce the evolution equations of the radiation optical field for the spontaneous emission and the self-amplified stimulated emission of the prebunched electron beam (Sec. III). In Sec. IV we analyze and discuss the behaviors of the FELs with the prebunched electron beam, and compare them with the seeding modes. Finally, Sec. V is devoted to concluding remarks.

II. BASIC EQUATION

Under the slowly varying envelope approximation the optical field equation and the ponder motive phase equation in one-dimensional FEL mode are [10-15]

$$\frac{d\tilde{a}_s}{dz} = \frac{\lambda_s r_e a_u f_c n_e}{\gamma} \langle e^{-i\phi} \rangle, \tag{1}$$

$$\frac{d^2\phi}{dz^2} = -\frac{2k_u k_s a_u f_c}{\gamma^2} \operatorname{Re}(\tilde{a}_s e^{i\phi}), \qquad (2)$$

where $\tilde{a}_s = a_s e^{-i\varphi_s}$, $a_s = eE_s/(mc^2k_s)$ and $a_u = eB_u/(mc^2k_u)$ are dimensionless vector potential of the *rms* radiation field E_s and undulator field B_u , respectively; $k_s = 2\pi/\lambda_s$, $k_u = 2\pi/\lambda_u$ are the corresponding wave numbers; φ_s is the phase of the radiation field; r_e is the classical electron radius; n_e and γ is the density and the energy

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of the electrons; f_c is the undulator coupling factor: for the circularly polarized helical undulator $f_c = 1$; for the linearly polarized planar undulator it is a difference of the two Bessel functions $f_c = J_0(\zeta) - J_1(\zeta)$, $\zeta = a_u^2/2(1 + a_u^2)$; the angular bracket represents the average over the electron's initial phases and initial phase velocities. The ponderomotive phase of electron is $\phi = (k_s + k_u)z - \omega_s t$, it can be written as

$$\phi = \phi_0 + \phi'_0 z + \Delta \phi, \tag{3}$$

where ϕ_0 and ϕ'_0 are the initial phase and the phase velocity (i.e. the detuning parameter, it is proportional to the resonance energy offset of the electron), $\Delta \phi$ is the phase change due to interaction with the optical field and can be given from Eq. (2):

$$\Delta \phi = -2k_s k_u a_u f_c \operatorname{Re} \int \int \frac{\tilde{a}_s e^{i\phi}}{\gamma^2} dz'' dz'$$
$$= -2k_s k_u a_u f_c \operatorname{Re} \int_0^z (l-z') \frac{\tilde{a}_s e^{i\phi}}{\gamma^2} dz'. \qquad (4)$$

When the optical field is not strong, the electron phase change due to interaction with the optical field is not large, then the exponential term in Eq. (1) can be linearized, thus we have

$$e^{-i\phi} = e^{-i[\phi_0 + \phi'_0 z + \Delta\phi]} \cong e^{-i[\phi_0 + \phi'_0 z]} (1 - i\Delta\phi).$$
 (5)

Here in the expression of the $\Delta\phi$, we neglect the perturbation part of the phase in the exponential of the integral. Inserting Eqs. (4) and (5) into Eq. (1) and averaging over the initial distribution of electrons in the phase space, we obtain

$$\frac{d\tilde{a}_s}{dz} = I_T \langle e^{-i(\phi_0 + \phi'_0 z)} \rangle$$

$$- (2k_u \rho)^3 \left[\left\langle \frac{\partial}{\partial \phi'_0} \int_0^z e^{-i\phi'_0(z-z')} \tilde{a}_s dz \right\rangle_{\phi'_0} \right]$$

$$- i \left\langle \int_0^z (z-z') e^{-i[2\phi_0 + \phi'_0(z+z')]} \tilde{a}_s^* dz \right\rangle . \quad (6)$$

Here $I_T = r_e \lambda_s a_u f_c n_e / \gamma$, it is proportional to the transverse current intensity, ρ is the Pierce parameter, $(2\gamma\rho)^3 = r_e n_e \lambda_u^2 a_u^2 f_c^2 / 2\pi$. For the usual FEL's theoretical analysis, an electron beam with uniform initial phase distribution is assumed, *i.e.* no initial bunching, therefore the first term (and the third term) on the right-hand side of the above equation is neglected and only the second term is considered. But for the electron beam being initially prebunched, the first term cannot be neglected on the right-hand side of Eq. (6).

Considering the monoenergy electron beam and neglecting the second-harmonic initial bunching, Eq. (6) becomes

$$\frac{d\tilde{a}_s}{dz} = I_T \tilde{b}_0 e^{-i\phi_0' z} - (2k_u \rho)^3 \frac{\partial}{\partial \phi_0'} \int_0^z e^{-i\phi_0' (z-z')} \tilde{a}_s dz, \qquad (7)$$

where $\tilde{b}_0 = \langle e^{-i\phi_0} \rangle$ is the initial bunching factor.

III. RADIATION FROM PREBUNCHED ELECTRON BEAM

First, we consider the spontaneous emission of the prebunched electron beam, the case in which the interaction between the electrons and the radiation field can be neglected, and without seeding ($a_{s0} = 0$). Therefore we neglect the changes of the electron phase due to the interaction with the optical field and only consider the first term on the right-hand side of Eq. (7). We get the radiation field and the power:

$$\tilde{a}_{s} = I_{T} \tilde{b}_{0} L \sin c \frac{\phi_{0}' L}{2} e^{-i\frac{\phi_{0}'}{2}L},$$

$$P = (2k_{u}\rho L)^{2} b_{0}^{2}\rho P_{e} \sin c^{2} \frac{\phi_{0}' L}{2},$$
(8)

where $P_e = I\varepsilon_e/e$ is the power of the electron beam, *I* and $\varepsilon_e = mc^2\gamma$ are the peak current and the energy of the electron beam, respectively.

For the ideal case that the electrons are full modulated, namely all the electrons are in the same phase, the bunching factor $b_0 = 1$, and the emission is completely coherent (superradiance), then from Eq. (8) it has (consider the resonant case $\phi'_0 = 0$)

$$P_{\rm sup} = (2k_u \rho L)^2 \rho P_e. \tag{9}$$

Thus the superradiance power is proportional to the square of the electron numbers and quadratically growing with the undulator length.

For the general case the optical field evolution equation [Eq. (7)] can be solved by Laplace transform:

$$\mu \tilde{a}_s(\mu) = \frac{I_T \tilde{b}_0}{\mu + i\phi'_0} + i(2k_u\rho)^3 \frac{\tilde{a}_s(\mu)}{(\mu + i\phi'_0)^2}.$$
 (10)

The solution is

$$\begin{split} \tilde{a}_{s}(z) &= \sum \operatorname{Res} \frac{I_{T} \tilde{b}_{0}(\mu + i\phi_{0}')e^{\mu z}}{\mu(\mu + i\phi_{0}')^{2} - i(2k_{u}\rho)^{3}} \\ &= i(2k_{u}\rho)^{3} \sum_{m=1}^{3} \frac{I_{T} \tilde{b}_{0}e^{\mu_{m} z}}{\mu_{m}(\mu_{m} + i\phi_{0}')(\mu_{m} - \mu_{l})(\mu_{m} - \mu_{k})} \\ &= \sum_{m=1}^{3} \frac{I_{T} \tilde{b}_{0}e^{\mu_{m} z}}{3\mu_{m} + i\phi_{0}'}, \end{split}$$
(11)

where μ_m are roots of the well-known FEL cubic equation: $\mu(\mu + i\phi'_0)^2 = i(2k_u\rho)^3$. When $\phi'_0/(2k_u\rho) < 3/\sqrt[3]{4} = 1.89$, the cubic equation has one imaginary root corresponding to the oscillatory mode of the optical field, and two complex roots with the real parts of equal magnitude but opposite sign, corresponding to the exponential amplifying mode and the exponential decaying mode, respectively [16]. [If $\phi'_0/(2k_u\rho) > 1.89$ the cubic equation will have three imaginary roots']

At the resonant energy, the detuning parameter $\phi'_0 = 0$, the roots of the cubic equation are $\mu = (2k_u\rho)i^{1/3}$. Then the radiation power of the prebunched electron beam is obtained as

$$P = \frac{2b_0^2 \rho P_e}{9} \left[ch(\bar{z}) - \cos\left(\frac{\sqrt{3}}{2}\bar{z}\right) ch\left(\frac{\bar{z}}{2}\right) + \sqrt{3}\sin\left(\frac{\sqrt{3}}{2}\bar{z}\right) sh\left(\frac{\bar{z}}{2}\right) \right],$$
(12)

where $\bar{z} = z/L_g$, $L_g = 1/2k_u\sqrt{3}\rho$ is the power gain length. For comparison the optical power from the amplification of a seeding is (resonance $\phi'_0 = 0$) [17]

$$P = \frac{P_0}{9} \left\{ 1 + 4ch\left(\frac{\bar{z}}{2}\right) \left[ch\left(\frac{\bar{z}}{2}\right) + \cos\left(\frac{\sqrt{3}}{2}\bar{z}\right) \right] \right\} \approx \frac{1}{9} P_0 e^{\bar{z}}.$$
(13)

The final exponential gain approximation is valid for $z > 4L_q$.

For a sufficiently long undulator $(z > 4L_g)$, see next section), the leading role is the exponential growth term corresponding to the root with positive real part. At the resonant energy it is $\mu_1 = k_u \rho(\sqrt{3} + i)$, then from Eq. (11) the exponential growth can be given as

$$\tilde{a}_{s}(z) \approx \frac{I_{T}\tilde{b}_{0}e^{k_{u}\rho(i+\sqrt{3})z}}{3k_{u}\rho(i+\sqrt{3})}, \qquad P \approx \frac{1}{9}b_{0}^{2}\rho P_{e}e^{\bar{z}}.$$
 (14)

We can see it is equivalent to the exponential amplification [Eq. (13)] of a seeding power of $P_0 = b_0^2 \rho P_e$.

Notice that we can write the optical field equation [Eq. (1)] as $d\tilde{a}_s/dz = I_T\tilde{b}$, hence from Eq. (14) the evolution of the bunching factor in the exponential gain region is

$$\tilde{b} \approx \frac{1}{3} \tilde{b}_0 e^{\mu_1 z}$$
 or $b^2 = \frac{1}{9} b_0^2 e^{\frac{z}{L_g}} (z > 4L_g).$ (15)

Therefore the emission power also can be written as

$$P \approx b^2 \rho P_e. \tag{16}$$

Generally it has b < 1. Considering the ideal case that the bunching factor reaches the ultimate $b \sim 1$, then the exponential gain reaches its maximum: $P_s = \rho P_e$.

We consider some schemes with the initial bunched electron beam.

The harmonic generation FEL schemes, including the superradiance FEL such as coherent harmonic generation (CHG) [18] and the high gain FEL such as high gain

harmonic generation (HGHG) [19–20], are a special kind of prebunching mode, in which a seeding laser and a configuration of two undulators separated by a dispersive section are adopted. In the first undulator, which is tuned at the seed wavelength and called the modulation section, the electron energy is modulated owing to the strong optical field of the external seeding laser. Then in the dispersive section, with the stronger dispersive magnetic field, the electron microbunching is formed quickly. Next, in the second undulator, which is tuned at the *n*th harmonic of the seeding laser and called the gain section, the radiation at the wavelength is enhanced. The initial bunching factor in the gain section undulator is

$$b_0 = J_n \left(nD \frac{\Delta \gamma_m}{\gamma} \right) \exp\left[-\frac{1}{2} \left(nD \frac{\sigma_{\gamma}}{\gamma} \right)^2 \right] = J_n f_{\gamma}, \quad (17)$$

where $D = 2\pi(N_1 + 2N_d)$, N_d is the dispersive parameter of the dispersive section, N_1 is the number of the modulation undulator periods; $\Delta \gamma_m$ is the maximum energy modulation of the electron beam by the seeding laser, σ_γ is the energy spread of the electron beam. We denote the Bessel function factor and the energy spread factor in Eq. (17) as J_n and f_γ respectively. The corresponding radiation power of the HG-FEL can be given by substituting Eq. (17) into Eq. (12).

When the length of the gain section undulator is shorter than four gain lengths, the radiation is the CHG [21]. Substituting Eq. (17) into Eq. (8), the radiation power of CHG FEL is

$$P = (2k_u \rho L)^2 J_n^2 f_r^2 \rho P_e.$$
 (18)

When the length of the gain section undulator is longer than four gain lengths, the evolution of the optical field becomes the HGHG process [21]. Substituting Eq. (17) into Eq. (14), the optical power of HGHG is

$$P \approx \frac{1}{9} J_n^2 f_r^2 \rho P_e e^{\frac{z}{L_g}}.$$
 (19)

For the echo-enabled harmonic generation (EEHG) scheme [22] the initial bunching factor in the gain section can be written as

$$b_{n} = J_{n+1} \left(n \frac{\Delta \gamma_{m2}}{\gamma} D_{2} \right) J_{1} \left[\frac{\Delta \gamma_{m1}}{\gamma} (n D_{2} - D_{1}) \right] e^{-\frac{\sigma_{\gamma}^{2}}{2\gamma^{2}} [n D_{2} - D_{1}]^{2}}.$$
(20)

Here $D_1 = 4\pi [N_{d1} + (N_1 + N_2)/2]$, $D_2 = 4\pi (N_{d2} + N_2/2)$, are the dispersive intensities of the first and the second stage of EEHG, respectively. Taking $D_1 \Delta \gamma_{m1}/\gamma \approx$ $n\pi$ and $nD_2 \Delta \gamma_2/\gamma = n + 1 + 0.81(n + 1)^{1/3}$, then for $\Delta \gamma_1/\sigma_\gamma \gg 1$, it has $b_n \approx 0.39/(n + 1)^{1/3}$. Substituting it into Eq. (12), the optical power of EEHG can be given. In the exponential gain region $(z > 4L_g)$, from Eq. (14) the optical power is

$$P \approx \frac{1}{60} \frac{1}{(n+1)^{2/3}} \rho P_e e^{\frac{z}{L_g}}.$$
 (21)



FIG. 1. The optical power growing vs undulator length $(\phi'_0 = 0)$. The red line (b): the prebunched mode [Eq. (12)]. The pink dashed line (c): the coherent spontaneous emission [Eq. (8)]. The blue dot line (e): the exponential gain formula [Eq. (14)]. The black line(s): the seeded amplifier mode [Eq. (13)].

IV. DISCUSSION

The variation of the optical power with the undulator length for the prebunched electron beam [Eq. (12)] is plotted in Fig. 1 (curve b). We can see that when $L < 4L_g$ it is just the coherent spontaneous emission [Eq. (8), curve c]; when $L > 4L_g$ it becomes the exponential growth of the stimulated emission [Eq. (14), curve e]. For comparison, we also plot the optical power of the seeded FEL amplifier [Eq. (13), curve s]. It is shown that the large difference is at the initial stage ($z < 4L_g$). The optical power induced by the electron initial bunching is developed from zero, its exponential growth is the same as the seeding mode.

Using Eq. (11) we give the emission intensity variation with the detuning parameter ($\eta = \delta \gamma / \gamma = \phi'_0 / 2k_u$) of the prebunching mode for different gain lengths (Fig. 2). The case of the seeding mode [16] is also shown for comparison. It can be seen that the two cases have the larger difference in the initial stage and tend to identical when entering the exponential gain region ($z > 4L_q$).

For the optical field growth induced by the prebunching electron beam, the detuning parameter corresponding to the maximum growth is initially at resonance $\eta_m/\rho \approx 0$ for the coherent spontaneous emission, then as the length of the undulator increases it becomes larger and remains at about $\eta_m/\rho \approx 0.1$ for the exponential gain. However, the growth



FIG. 2. The variation of the emission intensity with the detuning parameter for different interaction length. The solid line: prebunching mode; the dashed line: seeding mode.



FIG. 3. Shortened saturation length with initial bunching [Eq. (22)] and seed power [Eq. (23)].

at resonance differed little from the maximum growth, therefore the expression of the optical field at resonance [Eq. (12)] can be used to describe the maximum growth approximately. The gain bandwidth of the prebunching mode decreases from $\Delta \eta / \rho \approx 10 L_g / L$ (FWHM) for the coherent spontaneous emission to $\Delta \eta / \rho \approx 1$ for the exponential gain near saturation.

For the optical field growing from the seeding, the initial stage is the small signal gain region, the detuning parameter corresponding to the maximum growth and the gain bandwidth are $\eta_m/\rho = 2.6/4\pi N$ and $\Delta \eta/\rho \approx 6.6L_g/L$, respectively. Both of them decrease with increasing of the undulator length [16].

The saturation length of the exponential gain for the prebunched mode can be written as

$$L_{s} = L_{s0} - 2\ln\left(\frac{b_{0}}{b_{0,s}}\right)L_{g},$$
(22)

where L_{s0} is the saturation length of self-amplified spontaneous emission (SASE), $b_{0,s}$ is the equivalent initial bunching factor of SASE. Typically $b_{0,s}$ is smaller than 10^{-3} , therefore, even an initial bunching factor of not too large, e.g. 0.5%, can be expected to overwhelm the shotnoise induced bunching of SASE, and substantially decrease the saturation length (Fig. 3) [8].

Similarly, the saturation length for the amplifier mode (the seeding laser is amplified directly) is

$$L_s = L_{s0} - \ln\left(\frac{P_0}{P_{ef}}\right) L_g,\tag{23}$$

where P_0 is the power of the seeding; P_{ef} is the effective initial power of SASE, it is about the spontaneous radiation on two exponential gain lengths and has $P_{ef} = b_{0.s}^2 \rho P_e$.

V. SUMMARY

From the FEL equations, we have analyzed the emissions of the prebunched electron beam, including the coherent spontaneous emission and the self-amplified stimulated emission. For the spontaneous emission, neglecting the phase changes due to the interaction of the electron with the radiation field we give the formula of coherent spontaneous emission, the power of which is proportional to the square of the initial bunching factor and of the undulator length. For the general emission case of the prebunched electron beam, we deduced the evolution equation of the radiation field. Then for the resonant case, we obtained the analytical expression of the emission power; the application scope of it is from the low gain regions to the high gain regions. We find that it is just the coherent spontaneous emission when the undulator length is shorter than four gain lengths, and conversely, it is the exponential gain of the self-amplified stimulated emission. For the nonresonant prebunched electron beam, we show the variations of the emission intensity with the detuning parameter for different interaction length. We also compared the radiation field characters of the prebunched electron beam with that of the seeded FEL amplifier, such as the evolution of the optical field, the saturation length, the variation of the detuning parameter corresponding to the maximum gain and the variation of the gain bandwidth with the interaction length.

The analytical results presented here will provide help to the design and analysis of a THz FEL or X-FEL devices with the prebunching mode, and also help to develop insights into understanding the FEL gain process. For further studies, the more practical influence factors should be considered, such as the space charge effect, the effect of the imperfect electron beam, the diffraction effect and so on.

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